

AMENDMENTS TO THE CLAIMS

This Listing Of Claims will replace all prior versions, and listings, of the claims in the application.

Listing of the Claims:

Claim 1 (Currently Amended): A coating film-forming method, which method comprises coating a cationic electrodeposition coating composition onto a substrate by an electrodeposition coating, followed by heat curing to form a cured electrodeposition coating film, said cationic electrodeposition coating composition containing a base resin consisting of an amine-added epoxy resin (A) obtained by reacting an epoxy resin (a₁) with a modifying agent consisting of an epoxy compound (a₃) of a polyhydric polyol and with a polyphenol compound (a₅) to form a modified epoxy resin, followed by adding an amino group-containing compound (a₆) to the modified epoxy resin for reacting, ~~at least one modifying agent selected from the group consisting of a polyhydric polyol (a₂), an epoxy compound (a₃) of the polyhydric polyol and a cyclic ester compound (a₄), a polyphenol compound (a₅) and an amino group-containing compound (a₆),~~ and a curing agent consisting of a blocked polyisocyanate curing agent (B) obtained by reacting at least one polyisocyanate compound (b₁) selected from the group consisting of an aromatic polyisocyanate compound and an alicyclic polyisocyanate compound with at least one blocking agent (b₂) selected from the group consisting of an oxime compound, aliphatic alcohols, aromatic alkyl alcohols and ether alcohols.

Claim 2 (Previously Presented): A coating film-forming method as claimed in Claim 1, wherein the amine-added epoxy resin (A) has a glass transition temperature in the range of -10 to 60°C, and the blocked polyisocyanate curing agent (B) has a glass transition temperature in the range of -10 to 50°C.

Claim 3 (Previously Presented): A coating film-forming method as claimed in Claim 1, wherein the cationic electrodeposition coating composition further contains a bismuth compound as an anti-corrosive agent.

Claim 4 (Currently Amended): A coating film-forming method as claimed in Claim 1, wherein a coating film formed in one minute from starting of energizing on carrying out the electrodeposition coating one minute after starting of energizing on the electrodeposition coating, a resulting coating film has an electrical resistance in the range of $400\text{ k}\Omega\cdot\text{cm}^2$ to $850\text{ k}\Omega\cdot\text{cm}^2$.

Claim 5 (Previously Presented): A coated product obtained by the method as claimed in Claim 1.

Claim 6 (Previously Presented): A coating film-forming method as claimed in Claim 2, wherein the cationic electrodeposition coating composition further contains a bismuth compound as an anti-corrosive agent.

Claim 7 (Currently Amended): A coating film-forming method as claimed in Claim 2, wherein a coating film formed in one minute from starting of energizing on carrying out the electrodeposition coating one minute after starting of energizing on the electrodeposition coating, a resulting coating film has an electrical resistance in the range of $400\text{ k}\Omega\cdot\text{cm}^2$ to $850\text{ k}\Omega\cdot\text{cm}^2$.

Claim 8 (Currently Amended): A coating film-forming method as claimed in Claim 3, wherein a coating film formed in one minute from starting of energizing on carrying out the electrodeposition coating one minute after starting of energizing on the electrodeposition coating, a resulting coating film has an electrical resistance in the range of $400\text{ k}\Omega\cdot\text{cm}^2$ to $850\text{ k}\Omega\cdot\text{cm}^2$.

Claim 9 (Previously Presented): A coated product obtained by the method as claimed in Claim 2.

Claim 10 (Previously Presented): A coated product obtained by the method as claimed in Claim 3.

Claim 11 (Previously Presented): A coated product obtained by the method as claimed in Claim 4.